

Destructive Single-Event Effects in Diodes

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Acronyms



- DUT Device Under Test
- EDS Energy Dispersive X-Ray Spectroscopy
- ETW Electronics Technology Workshop
- GSFC Goddard Space Flight Center
- I_F Forward Current
- I_R Reverse Current

- IR infrared
- LET Linear Energy Transfer
- NEPP NASA Electronics Parts and Packaging
- RF Radio Frequency
- SBD Super Barrier Diode
- SEE Single-Event Effects
- V_R Reverse Voltage
- V_F Forward Voltage



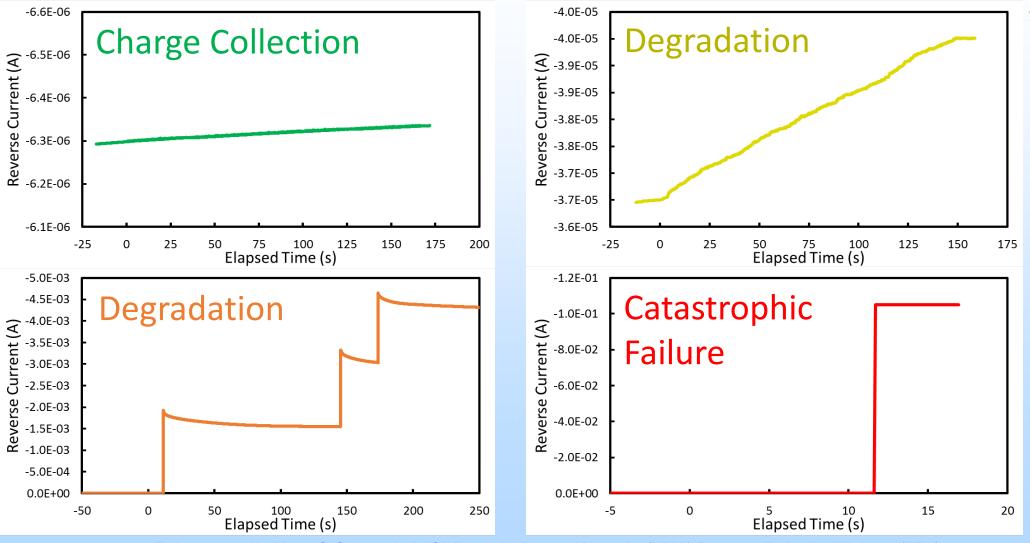
Background and Summary of Previous Results

Introduction



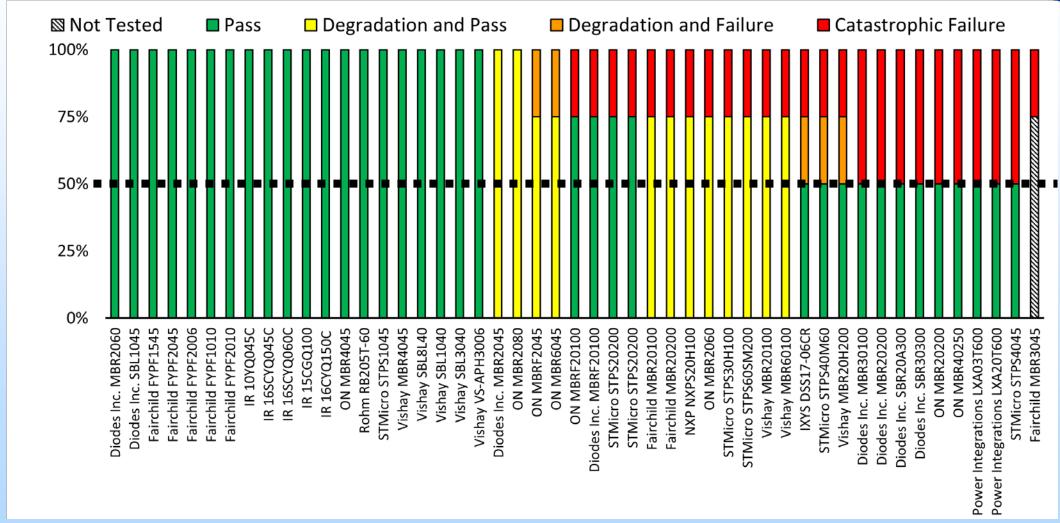
- Since 2011, GSFC has been investigating destructive SEEs in Schottky diodes
 - We have recommended a 50% V_R derating for operation in heavy-ion environments
- During this investigation, several super barrier diodes were also irradiated and experienced failures identical to the Schottky diodes that were tested
 - In retrospect, this is not totally unexpected as SBDs also have a Schottky junction, but also employs an insulating layer between the metal and semiconductor material
 - However, this led us to question whether the failure mechanism is limited to diodes with Schottky junctions or if it exists in other diode types as well

Background – Observed Radiation Responses



Background – Schottky Diode Results

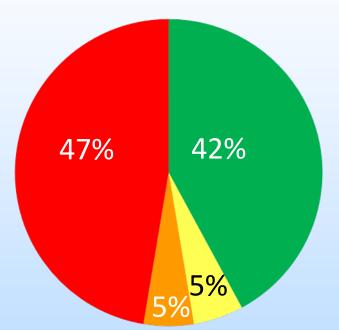




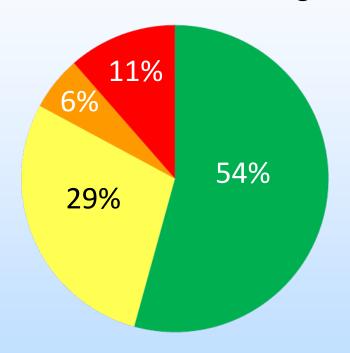
Background – Schottky Diode Results







75% of Reverse Voltage



50% of Reverse Voltage



By derating to 50% of the reverse voltage, all failures are eliminated for the parts tested



Current Results – Other Diode Types

Parts Tested



- 30 diodes from 10 manufacturers
- 5 diode types: avalanche, RF PiN, super barrier, switching, and Zener
- Reverse voltages range from 35 V to 200 V
- Forward currents (per diode) from 2 mA to 10 A

Test Facilities and Technique



- All parts were tested at LBNL's 88-inch cyclotron with 1233 MeV Xe (LET = 58.8 MeV-cm²/mg)
- All diodes were irradiated under reverse bias and at room temperature
- After each beam run, V_F, V_R, I_F and I_R were measured
- Because a 50% derating has been found to be sufficient for Schottky diodes, that was the initial test voltage
- A minimum of 3 DUTs per part type were tested

Diodes Tested

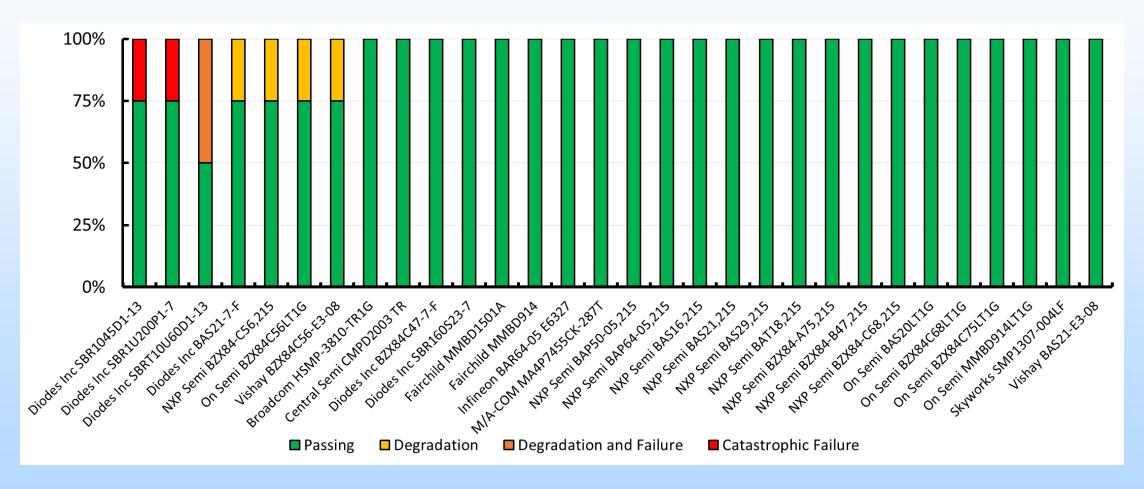


| Diode Type | Manufacturer | Part Number | Reverse Voltage | Forward Current |
|---------------|--------------|----------------|-----------------|-----------------|
| Avalanche | NXP Semi | BAS29,215 | 90 V | 200 mA |
| Super Barrier | Diodes Inc | SBR1U200P1-7 | 200 V | 1 A |
| Super Barrier | Diodes Inc | SBR1045D1-13 | 45 V | 10 A |
| Super Barrier | Diodes Inc | SBR160S23-7 | 60 V | 900 mA |
| Super Barrier | Diodes Inc | SBRT10U60D1-13 | 60 V | 10 A |
| Zener | Diodes Inc | BZX84C47-7-F | 47 V | 10 mA |
| Zener | NXP Semi | BZX84-B47,215 | 47 V | 10 mA |
| Zener | NXP Semi | BZX84-C56,215 | 56 V | 10 mA |
| Zener | NXP Semi | BZX84-C68,215 | 68 V | 10 mA |
| Zener | NXP Semi | BZX84-A75,215 | 75 V | 10 mA |
| Zener | On Semi | BZX84C56LT1G | 56 V | 10 mA |
| Zener | On Semi | BZX84C68LT1G | 68 V | 10 mA |
| Zener | On Semi | BZX84C75LT1G | 75 V | 10 mA |
| Zener | Vishay | BZX84C56-E3-08 | 56 V | 2 mA |

| Diode Type | Manufacturer | Part Number | Reverse Voltage | Forward Current |
|------------|--------------|-----------------|-----------------|-----------------|
| PiN | Broadcom | HSMP-3810-TR1G | 100 V | 1 A |
| PiN | Infineon | BAR64-05 E6327 | 150 V | 100 mA |
| PiN | M/A-COM | MA4P7455CK-287T | 100 V | 150 mA |
| PiN | NXP Semi | BAP64-05,215 | 175 V | 100 mA |
| PiN | NXP Semi | BAT18,215 | 35 V | 100 mA |
| PiN | NXP Semi | BAP50-05,215 | 50 V | 50 mA |
| PiN | Skyworks | SMP1307-004LF | 200 V | 100 mA |
| Switching | Central Semi | CMPD2003 TR | 200 V | 200 mA |
| Switching | Diodes Inc | BAS21-7-F | 200 V | 200 mA |
| Switching | Fairchild | MMBD914 | 100 V | 200 mA |
| Switching | Fairchild | MMBD1501A | 200 V | 200 mA |
| Switching | NXP Semi | BAS16,215 | 100 V | 215 mA |
| Switching | NXP Semi | BAS21,215 | 200 V | 200 mA |
| Switching | On Semi | MMBD914LT1G | 100 V | 200 mA |
| Switching | On Semi | BAS20LT1G | 200 V | 200 mA |
| Switching | Vishay | BAS21-E3-08 | 200 V | 200 mA |

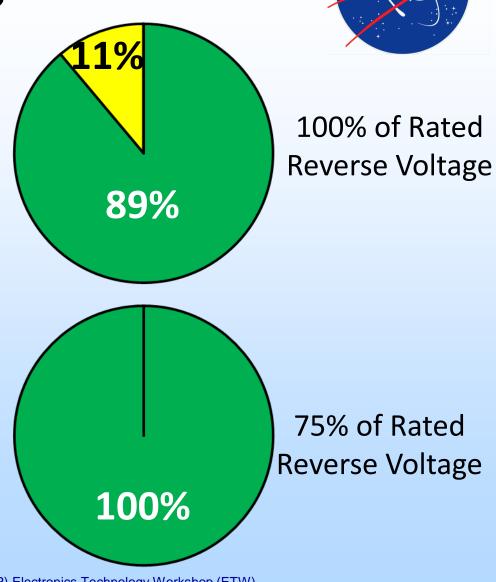
Results





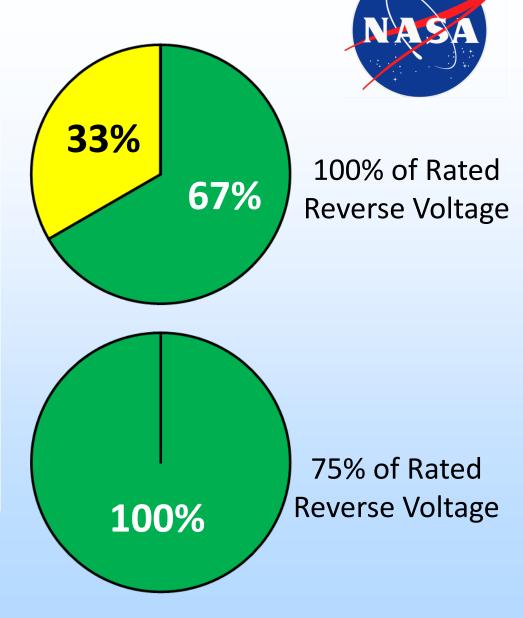
Results – RF Switching Diodes

| Manufacturer | Part Number | Reverse Voltage | Forward Current |
|--------------|-------------|-----------------|-----------------|
| Fairchild | MMBD914 | 100 V | 200 mA |
| NXP Semi | BAS16,215 | 100 V | 215 mA |
| On Semi | MMBD914LT1G | 100 V | 200 mA |
| Diodes Inc | BAS21-7-F | 200 V | 200 mA |
| Central Semi | CMPD2003 TR | 200 V | 200 mA |
| Fairchild | MMBD1501A | 200 V | 200 mA |
| NXP Semi | BAS21,215 | 200 V | 200 mA |
| On Semi | BAS20LT1G | 200 V | 200 mA |
| Vishay | BAS21-E3-08 | 200 V | 200 mA |



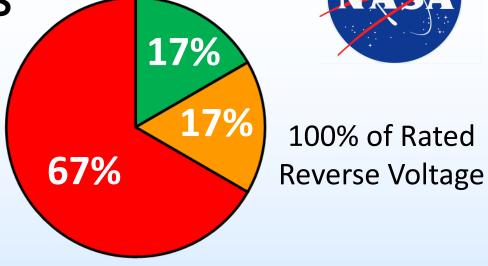
Results – Zener Diodes

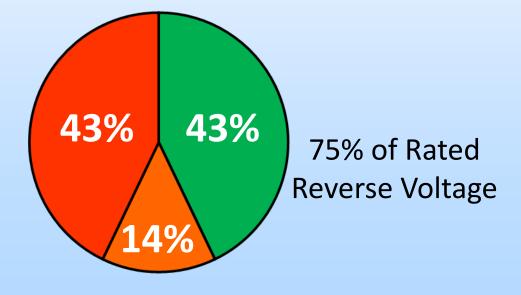
| Manufacturer | Part Number | Zener Voltage | Forward Current |
|---------------------|----------------|---------------|-----------------|
| Diodes Inc | BZX84C47-7-F | 47 V | 10 mA |
| NXP Semi | BZX84-B47,215 | 47 V | 10 mA |
| NXP Semi | BZX84-C56,215 | 56 V | 10 mA |
| On Semi | BZX84C56LT1G | 56 V | 10 mA |
| <mark>Vishay</mark> | BZX84C56-E3-08 | 56 V | 2 mA |
| NXP Semi | BZX84-C68,215 | 68 V | 10 mA |
| On Semi | BZX84C68LT1G | 68 V | 10 mA |
| NXP Semi | BZX84-A75,215 | 75 V | 10 mA |
| On Semi | BZX84C75LT1G | 75 V | 10 mA |



Results – Super Barrier Diodes

| Manufacturer | Part Number | Reverse Voltage | Forward Current |
|--------------|----------------|-----------------|-----------------|
| Diodes Inc | SBR1045D1-13 | 45 V | 10 A |
| Diodes Inc | SBRT10U60D1-13 | 60 V | 10 A |
| Diodes Inc | SBR160S23-7 | 60 V | 900 mA |
| Diodes Inc | SBR1U200P1-7 | 200 V | 1 A |
| Diodes Inc | SBR20A300 | 300 V | 10 A |
| Diodes Inc | SBR30300 | 300 V | 15 A |







Recap of 2016 ETW Presentation

2016 NEPP ETW



- Last year, I presented a case study of a 1N6843 from two different manufacturers being used on a flight project
 - The reverse voltage is 100 V and forward current is 10 A
 - Normal application reverse voltage is ~60 V and worst case application reverse voltage is ~82 V
 - There are currently no mission radiation requirements for diodes; so destructive SEEs requirements were used for this testing
- The irradiated parts experienced all four radiation responses
 - By conducting failure analysis on these DUTs, we are hoping to derive additional information about the failure mechanisms

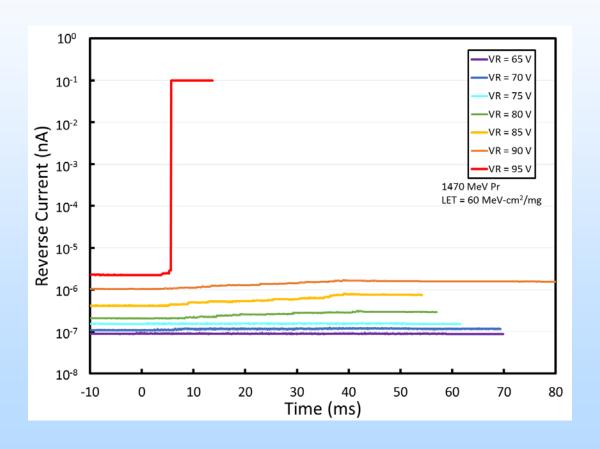


Failure Analysis

Power Supply Currents

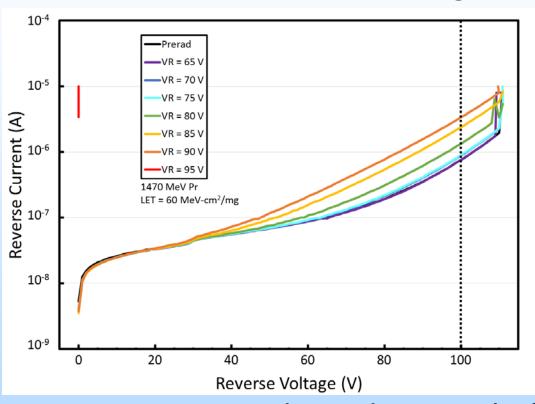
- SN5 was irradiated with 1470 MeV Pr (LET = 60 MeV-cm²/mg) in 5 V steps starting at 50 V (50% of the rated reverse voltage)
- Only charge collection was observed up to the 65-V irradiation
- When biased at 70 V, small increases in the reverse current were observed during the beam run
 - Post-irradiation electrical parameter measurements all remained within specification
 - Increases in reverse current were on the order of 100 nA
- At 95 V, the increase in reverse current was 100s of nA



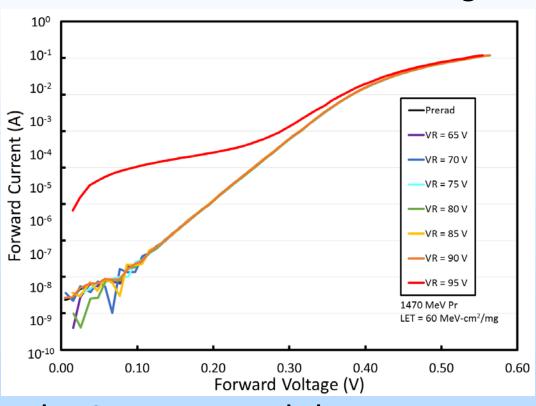


Post-Irradiation Electrical Measurements

Reverse Current vs. Reverse Voltage



Forward Current vs. Forward Voltage

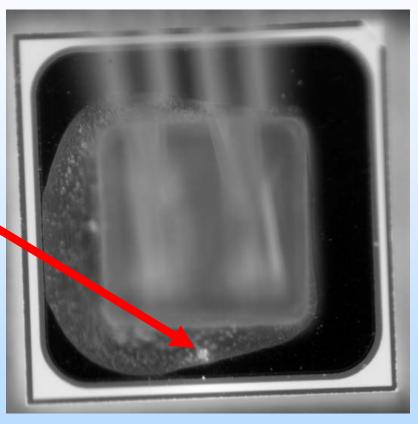


Part was degrading until after the 95-V run, and then I_{R} exceeded 10 μA at less than 1 V

Infrared Imaging of DUT

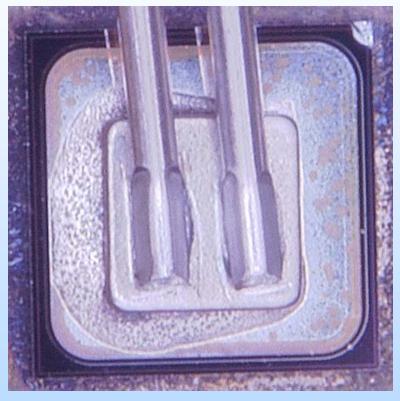


- Diode was examined using an IR camera and pictures were taken with a small voltage applied
 - Bright white spot just below the wirebond contact is the location of the failure
- Low-magnitude and highmagnitude optical images of the surface of the DUT did not show anything unusual at the location identified in the IR image



Optical Images of DUT

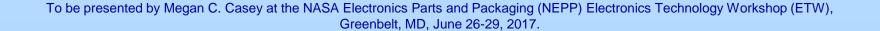
Low-Magnification



High-Magnification

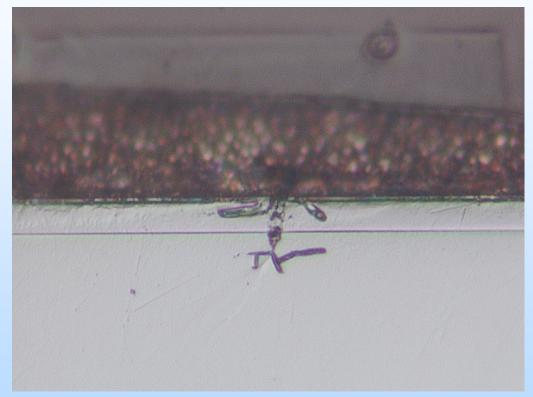


Failure location is not visible in optical images

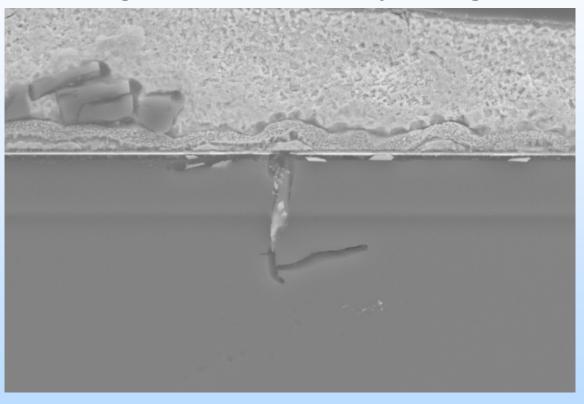


Cross-Section at Failure Location

High-Magnification Optical Image

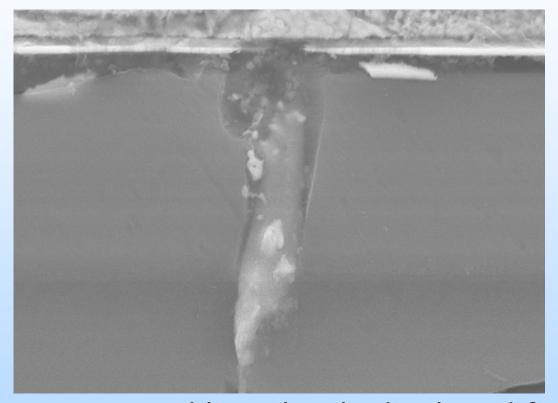


Scanning Electron Microscope Image

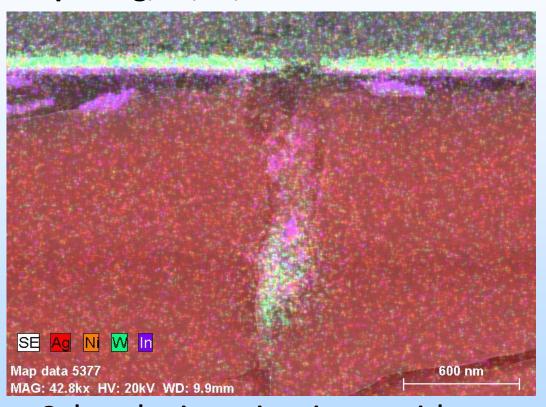


Energy Dispersive X-Ray Spectroscopy

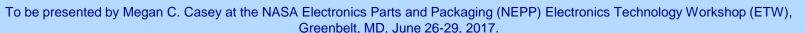
Magnification of SEM Image



Map of Ag, Ni, W, and In



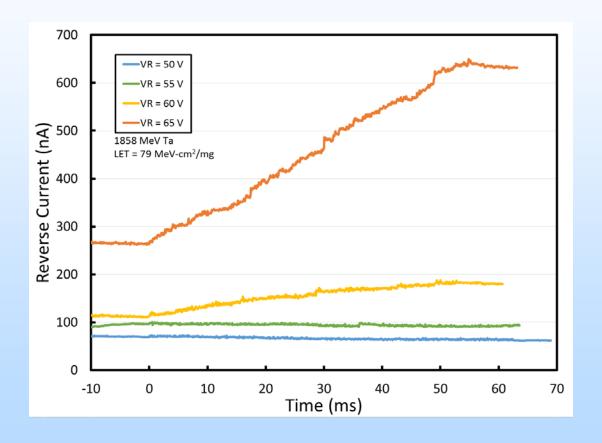
Metal has clearly displaced from Schottky junction into void formed from high current



Power Supply Currents

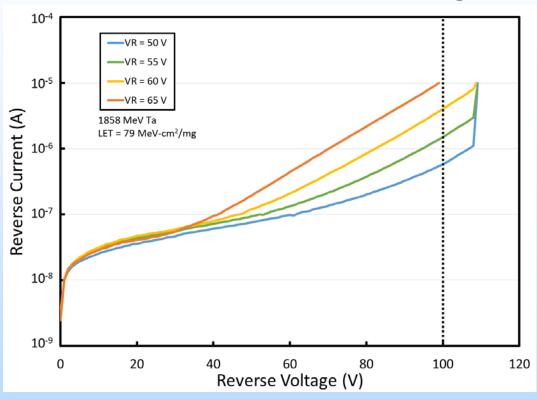
NASA

- SN2 was irradiated with 1858 MeV Ta (LET = 79 MeV-cm²/mg) in 5 V steps starting at 50 V (50% of the rated reverse voltage)
- Only charge collection was observed up to the 55-V irradiation
- When biased at 60 V, a ~60 nA increase in I_R was observed
 - All post-irradiation parameter measurements remained within specification
- At 65 V, however, DUT experienced 100s of nA in degradation and postirradiation I_R measurement was out of specification

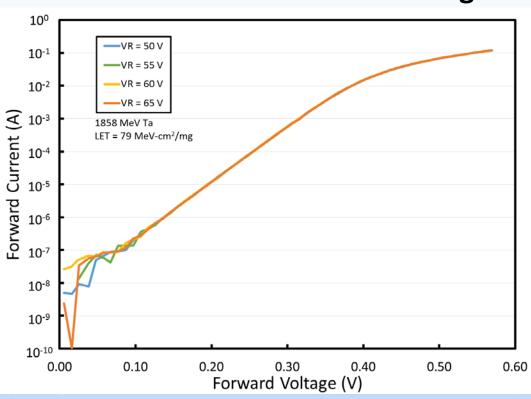


Post-Irradiation Electrical Measurements





Forward Current vs. Forward Voltage

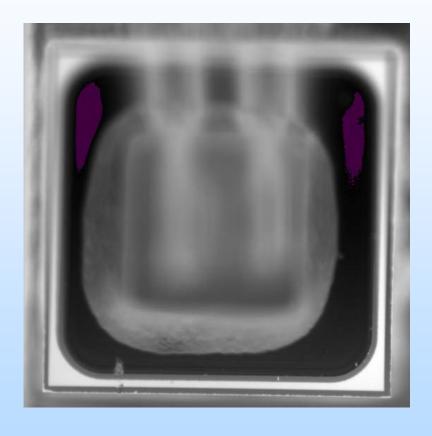


No significant changes were observed in the I_F - V_F curves, but I_R exceeded specification at less than 100 V

Infrared Imaging of DUT

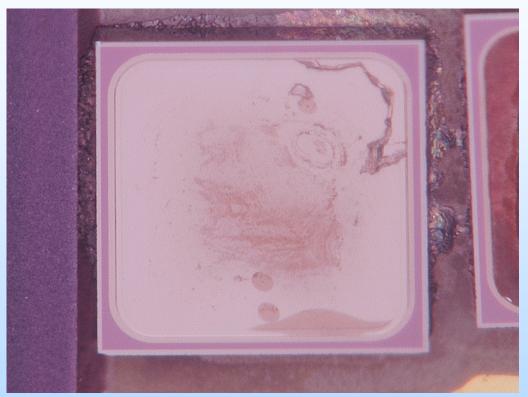
- Diode was examined using an IR camera and pictures were taken with a small voltage applied
 - No failure locations could be identified
- Low-magnitude and high-magnitude optical images of the surface of the DUT also did not show anything unusual
- Because no failure locations were identified, a different technique had to be used
 - A series of chemical etches were used to remove the contact pad, solder connection, and Schottky barrier metal



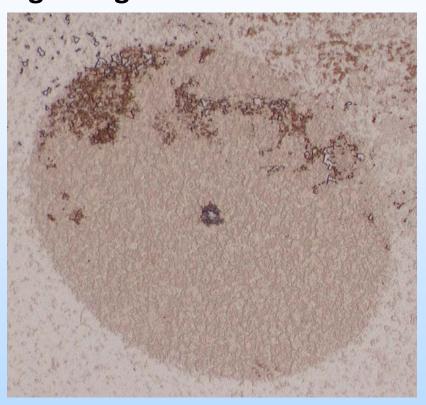


Optical Images of DUT

Low-Magnification



High-Magnification

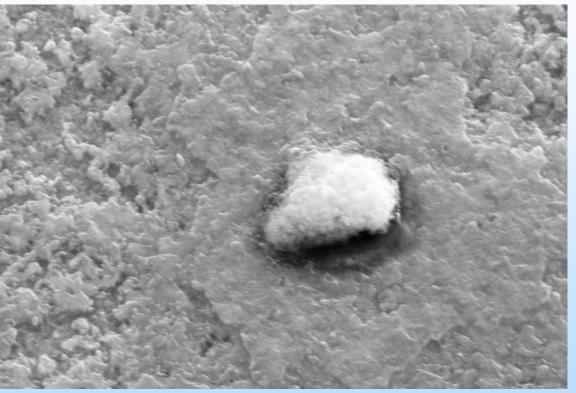


After chemical etches, a few small discolored locations were identified with displaced silicon at the center

Scanning Electron Microscope Images



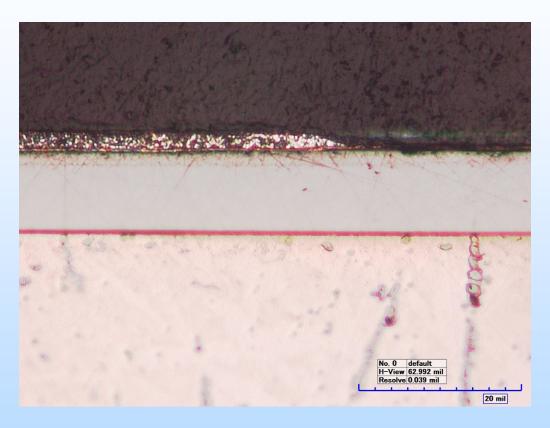




Displaced silicon ball was unable to be removed from surface of the diode

Cross-Section at Displaced Silicon Location



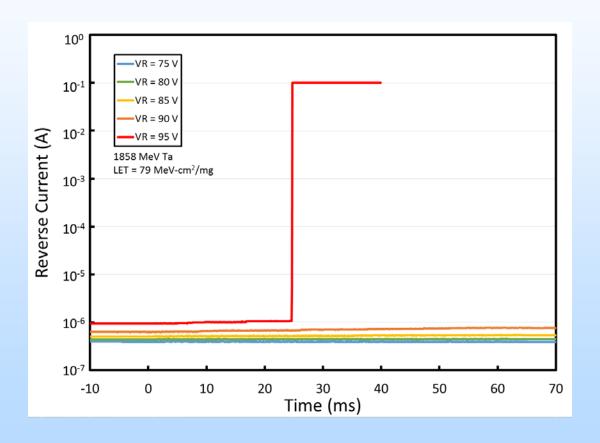


There is no damage structure visible in the damaged diode cross-section

Power Supply Currents

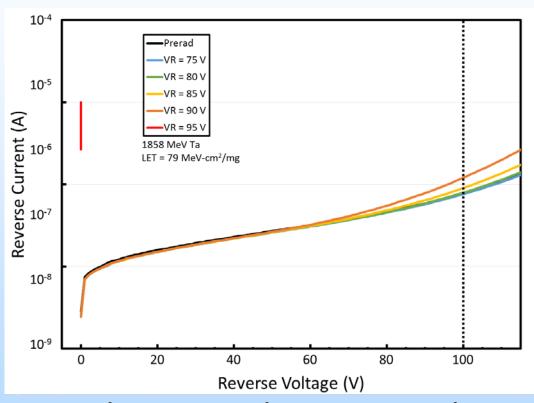
NASA

- SN7 was irradiated with 1858 MeV Ta (LET = 79 MeV-cm²/mg) in 5 V steps starting at 75 V
- Only charge collection was observed up to the 85-V irradiation
- When biased at 90 V, a ~140 nA increase in I_R was observed
 - All post-irradiation parameter measurements remained within specification
- At 95 V, the current reached the maximum 100 mA allowed by the power supply, and the anode and cathode were shorted together

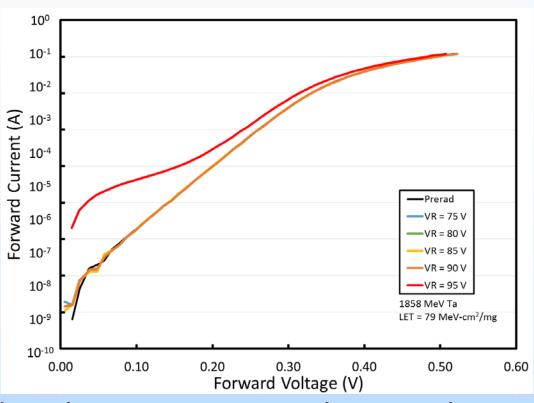


Post-Irradiation Electrical Measurements

Reverse Current vs. Reverse Voltage



Forward Current vs. Forward Voltage

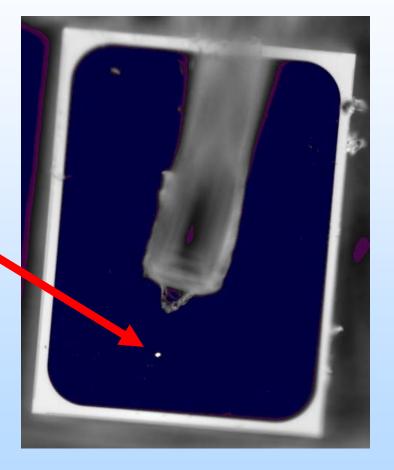


Almost no change was observed in the I_R - V_R or I_F - V_F plots until the 95-V irradiation, and then I_R exceeded 10 μA at less than 1 V

Infrared Imaging of DUT

NASA

- Diode was examined using an IR camera and pictures were taken with a small voltage applied
 - Bright white spot just below the wirebond contact is the location of the failure
- Low-magnitude and highmagnitude optical images of the surface of the DUT did not show anything unusual at the location identified in the IR image



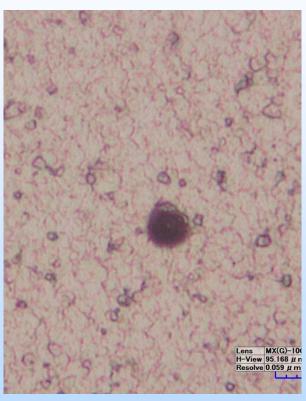
Optical Images of DUT

Low-Magnification



High-Magnification

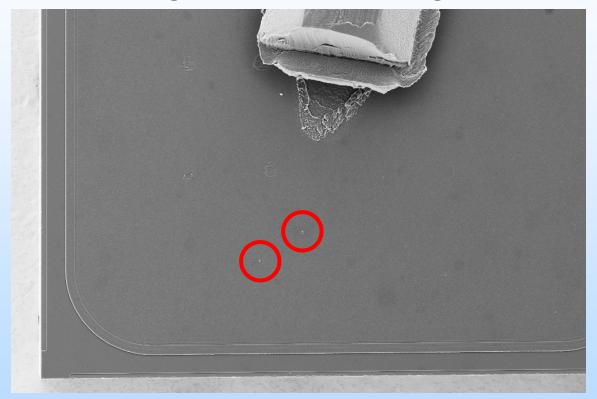




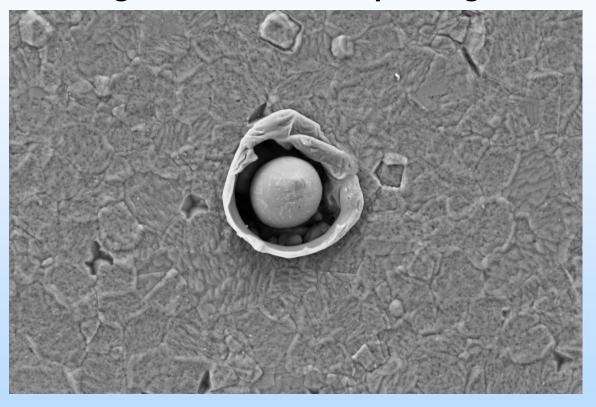
Unlike other part that experienced catastrophic failure, location is visible in high-magnification optical images

Surface SEMs of Failure Location

Low-Magnification SEM Image



Scanning Electron Microscope Image

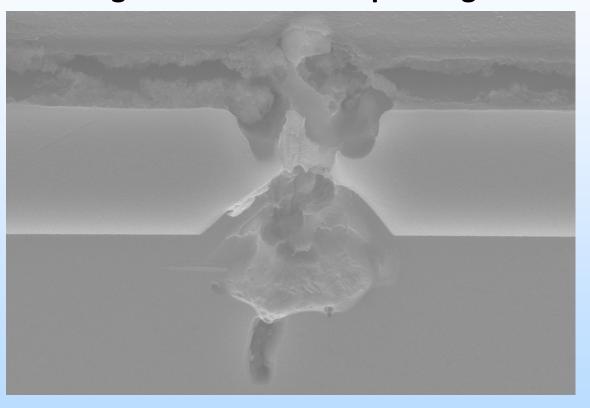


Cross-Section at Failure Location

High-Magnification Optical Image

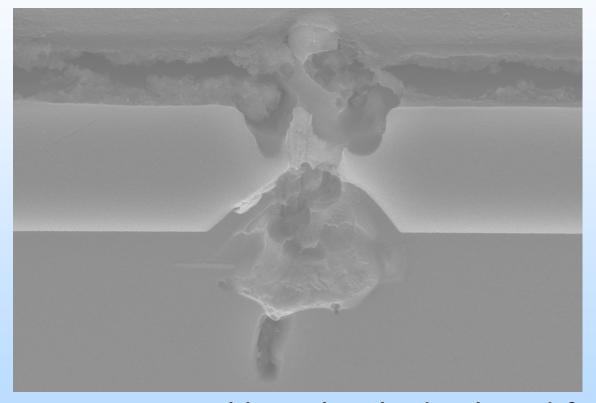


Scanning Electron Microscope Image

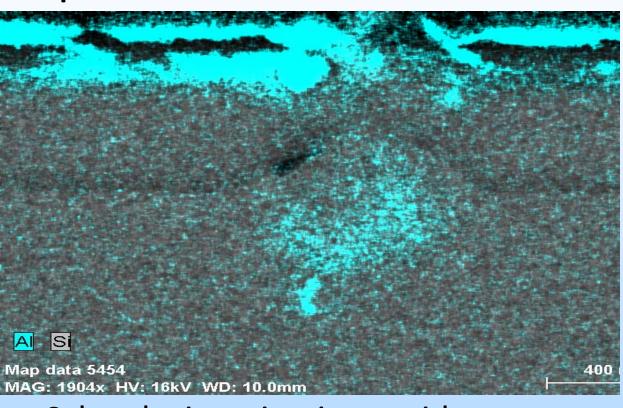


Energy Dispersive X-Ray Spectroscopy

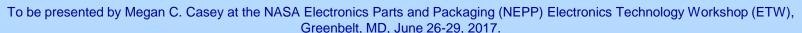
SEM Cross-Section Image



Map of Al and Si



Metal has clearly displaced from Schottky junction into void formed from high current





Conclusions

Conclusions

- Only diodes with a Schottky junction appear to experience catastrophic failure under the conditions tested
- Degradation was observed in an RF switching diode and several Zener diodes
 - While all measured electrical parameters remained within specification after degradation was observed, the long-term reliability of these parts is unknown
- Degradation and failure mechanisms are not limited to power devices
- Failure analysis shows clear failure locations in parts that experience catastrophic failure when examined with an IR camera
- Parts that experience degradation do not appear to have deep internal failure structures that are observable when cross-sectioned
- When the anode and cathode short in diodes due to destructive SEEs,
 Schottky metal displaces and creates the conducting path



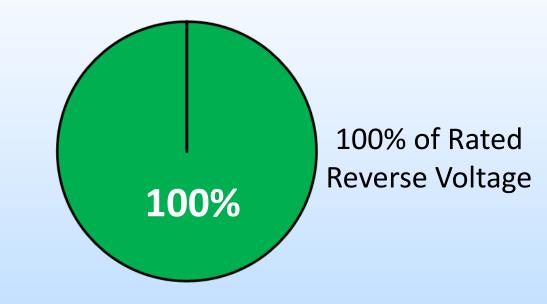
Backup Slides

Results – Avalanche Diode



- Only one avalanche diode type was tested
 - We were limited in our options due to packaging issues

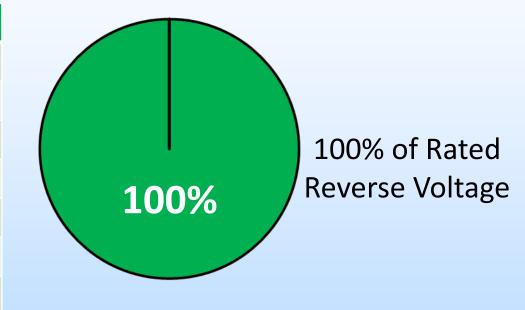
| Manufacturer | Part Number | Reverse Voltage | Forward Current |
|--------------|-------------|-----------------|-----------------|
| NXP Semi | BAS29,215 | 90 V | 200 mA |



Results – PiN Diodes



| Manufacturer | Part Number | Reverse Voltage | Forward Current |
|--------------|-----------------|-----------------|-----------------|
| NXP Semi | BAT18,215 | 35 V | 100 mA |
| NXP Semi | BAP50-05,215 | 50 V | 50 mA |
| Broadcom | HSMP-3810-TR1G | 100 V | 1 A |
| M/A-COM | MA4P7455CK-287T | 100 V | 150 mA |
| Infineon | BAR64-05 E6327 | 150 V | 100 mA |
| NXP Semi | BAP64-05,215 | 175 V | 100 mA |
| Skyworks | SMP1307-004LF | 200 V | 100 mA |



Diodes, Inc. BAS21-7-F Switching Diode

- Small changes in the reverse current were observed during the runs in which these parts were biased at the full-rated 200-V reverse voltage
- Small changes in the I_R-V_R and I_F-V_F plots were observed after the runs
 - How these changes effect the long-term reliability of the parts is unknown

